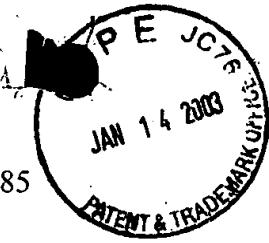


Docket No.: 52352-785



#8/election  
PATENT  
1/22/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of  
George Jonathan KLUTH, et al.

Serial No.: 10/071,207 : Group Art Unit: 2811

Filed: February 11, 2002 : Examiner: GUERRERO, Maria F.

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE WITH  
SUPERSATURATED SOURCE/DRAIN EXTENSIONS AND METAL SILICIDE  
CONTACTS

**RESPONSE TO RESTRICTION REQUIREMENT**

Commissioner for Patents  
Washington, DC 20231

Sir:

Noting the Office Action of December 31, 2002 wherein restriction has been required, the undersigned  
Applicant(s) hereby elect Group I (claims 1-18) with traverse for prosecution in the above-~~and by separate~~  
identified application.

To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby  
made. Please charge any shortage in fees due in connection with the filing of this paper, including  
extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit  
account.

Respectfully submitted,  
MCDERMOTT, WILL & EMERY

*Bernard P. Codd*

Bernard P. Codd  
Registration No. 46,429

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Date: January 14, 2003

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